

SEC.626

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re patent application of

Seung-dong KANG et al.

Group Art Unit: 2814

Serial No. 09/275,808

Examiner: G. Peralta

Filed: March 25, 1999

For: Method of Fabricating a Capacitor

Assistant Commissioner of Patents
Washington, D.C. 20231

**AMENDMENT AFTER FINAL UNDER 35 USC §116 AND
REQUEST FOR RECONSIDERATION**

Sir:

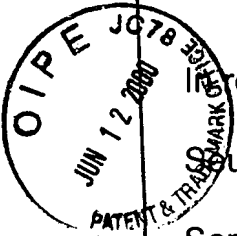
in response to the Office Action of February 10, 2000 in the above-identified application, kindly amend the application as follows.

In the Claims

Please amend claims 1, 5 - 7, 11, 13, 14, 16 and 17 as follows.

-- Claim 1. (Twice Amended) A method for forming a capacitor electrode of a capacitor in a reacting chamber, the method comprising:

forming a first [HSG] hemispherical grain (HSG) nuclei by introducing a first amount of a source gas into the reacting chamber while [an ambient] the



RECEIVED
JUN 14 2000
TC 2300 MAIL ROOM

7/B (2)
FJONES

6-16-00

OK to enter
6/19/00